

Docket No. 150.00560102

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s):	Whonchee Lee et al.)	Group Art Unit:	1765
Serial No.:	09/560,268)	Examiner:	D. Deo
Filed:	April 26, 2000))		
For:	METHOD AND COMPOSITE COBALT SILICIDE	ΓΊΟΝ F	OR SELECTIVELY E	TCHING AGAINST

Assistant Commissioner for Patents Washington D.C. 20231

Dear Sir:

nt Commissioner for Patents

In response to the Office Action mailed December 28, 2000, please consider the and amendments to the application. following remarks and amendments to the application.

In the Claims

Please cancel claim 36; amend claims 37-39; and add new claims 46-63. The new and amended claims are provided below in clean form. Per 37 C.F.R. § 1.121, amended claims are also shown in Appendix A with notations to indicate changes made (for convenience, all pending claims, including those new claims added hereby, are provided in Appendix A).

37. The etching composition according to claim 38, wherein the (Once Amended) \ mineral acid is HCl and the peroxide is hydrogen peroxide.

An etching) composition, the composition comprising a mineral 38. (Once Amended) acid, a peroxide, and deionized water at a ratio in a range of about 1:1:35 (mineral acid:peroxide:deionized water) to about 1:1:5 (mineral acid:peroxide:deionized water).

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